Topical Collection

Process Data Analytics

Message from the Collection Editors

This Special Issue, "Process Data Analytics", aims to bring together recent advances, and invites all original contributions, fundamental and applied, which can add to our understanding of the field. Topics may include, but are not limited to:

- Process data analytics methods
- Machine learning methods adapted for application to manufacturing processes
- Methods for better handling of missing data
- Fault detection and diagnosis
- Adaptive process monitoring
- Industrial case studies
- Applications to Big Data problems in manufacturing
- Hybrid data analytics methods
- Prognostic systems

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